



IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Application of:

Peter T. Aylward, et al

FINGERPRINT PROTECTION FOR CLEAR PHOTOGRAPHIC SHIELD

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Serial No. US 09/705,545

Filed 03 November 2000

Commissioner for Patents Washington, D.C. 20231

Sir:

Group Art Unit: 1752

Examiner: R. Schilling

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<u>AMENDMENT</u>

This amendment is in response to the Office Action dated November 12, 2002. In the above-captioned application, please enter the following amendments.

In the Specification

Please replace the paragraph beginning at page 9, line 18 with the following rewritten paragraph:

--To provide abrasion and scratch resistance to the photographic element of the invention, it is desirable to use tough polymers, cross-linked polymer, improve the lubricity of the layers or even add matte particles to aid in the reduction of the coefficient of friction. In addition, it is desirable to provide at least one layer that is electrically conductive to prevent static buildup and discharge. It is desirable to use materials and amounts in any or all of these layers that optically are very clear and do not interfere with the exposure of the photosensitive layers when the exposure is made through the base. Furthermore, these materials should not interfere with the viewing of the final developed and

